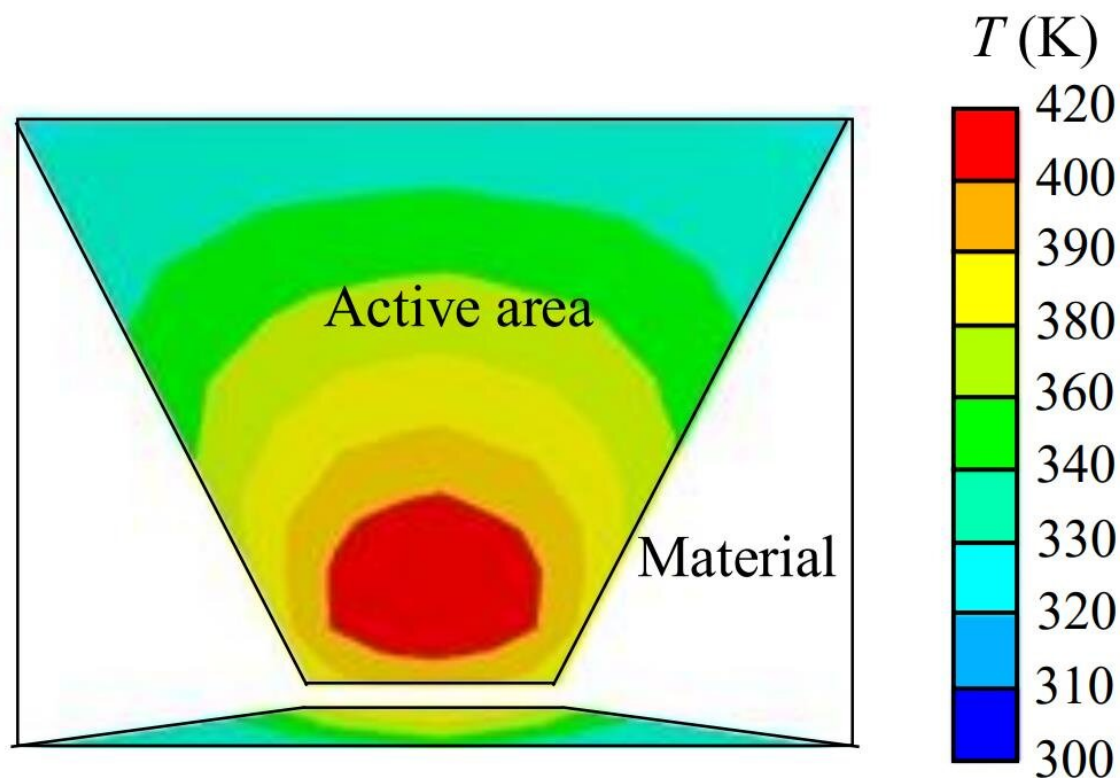


An intelligent model simulator that maps complex phenomena of memristor memory

September 4 2020



Snapshot depicts the temperature profile of the memristor memory model.
Credit: SUTD

Memristor memory technology is set to revolutionize computers the world over as it is touted as one of the most promising candidates used

for next-generation edge computing. This technology is attracting a lot of attention for replacing flash due to its implementations in high-efficient in-memory computing, machine learning and neuromorphic computation. Realizing a model to predict the phenomena of memristor memory technology accurately is essential as this will allow engineers to design systems with more efficient behaviors for making a cheaper, faster memory.

Currently, a wide range of experimental and modeling studies have been reported to understand the transport process, which occurs when a current passes through the device. Several important characteristics, such as applied voltage, [electric field](#), material constants and so on, are applied in the model simulators for predicting this process. Transport process can be analyzed by [various models](#) with the help of simulation tools and advanced observation technologies.

A Singapore-led collaboration has successfully created a simulator using both electronic and thermal components to make a "transport pattern." The team then used this hybrid platform to map a long-standing challenge in memory technology: the transport process under many conditions.

Corresponding author, Assistant Professor Desmond Loke from SUTD, said, "What we have done is take two different components of a model, memristor [model](#), which show different behavior from each other. When these are put them together, one can create a transport pattern that is up to 700 times more accurate than traditional models."

Due to Joule heating, the potential temperature of the device increases and yield variations in [electronic properties](#), such as mobility of electrons and depth of traps. These variations influence the analysis and prediction of transport behavior of memristor memory. By considering the models of transport behaviors and assumptions related to the electron

mobility and trap depth, the transport behaviors of memristor memory cells can be precisely predicted. Furthermore, the rich transport and switching behaviors can be fully accounted for by describing device characteristics obtained by an entirely new set of general current-limiting parameters.

More information: Qishen Wang et al, Analytical modeling electrical conduction in resistive-switching memory through current-limiting-friendly combination frameworks, *AIP Advances* (2020). [DOI: 10.1063/5.0019266](https://doi.org/10.1063/5.0019266)

Provided by Singapore University of Technology and Design

Citation: An intelligent model simulator that maps complex phenomena of memristor memory (2020, September 4) retrieved 10 April 2024 from <https://techxplore.com/news/2020-09-intelligent-simulator-complex-phenomena-memristor.html>

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